

# **Low Loss/ICHIRO shape cavity R&D at KEK**

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**KEK**

**ECFA-CLIC-ILC joint meeting**  
October 18-22, 2010, CERN

# KEK Low Loss/ICHIRO cavity strategies

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## **1) Principle proof of High gradient**

*Fine Grain + ICHIRO + EP, based on CBP*

S0-study at Jlab on ICHIRO#7 (full cavity) are on going.

End group singles R&D,

## **2) Cost reduction + best performance**

*Large Grain + ICHIRO + BCP, based on CBP*

Multi-wire slicing techniques is in hand.

Single cell, 9-cell R&D are on going.

## **3) Further goal: High gradient, High yield, Low cost**

*Large Grain + ICHIRO + BCP, inner EBW, w/ or w/o CBP*

Single crystal ingot R&D is started.

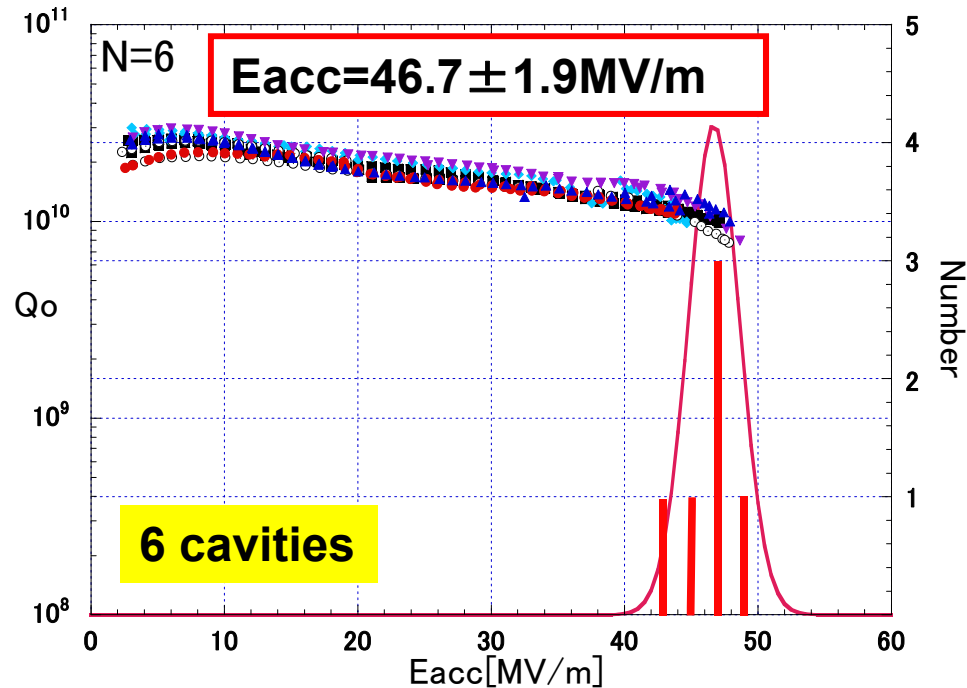
New LG full 9-cell will be delivered at end of November.

Post EP cleaning R&D on going.

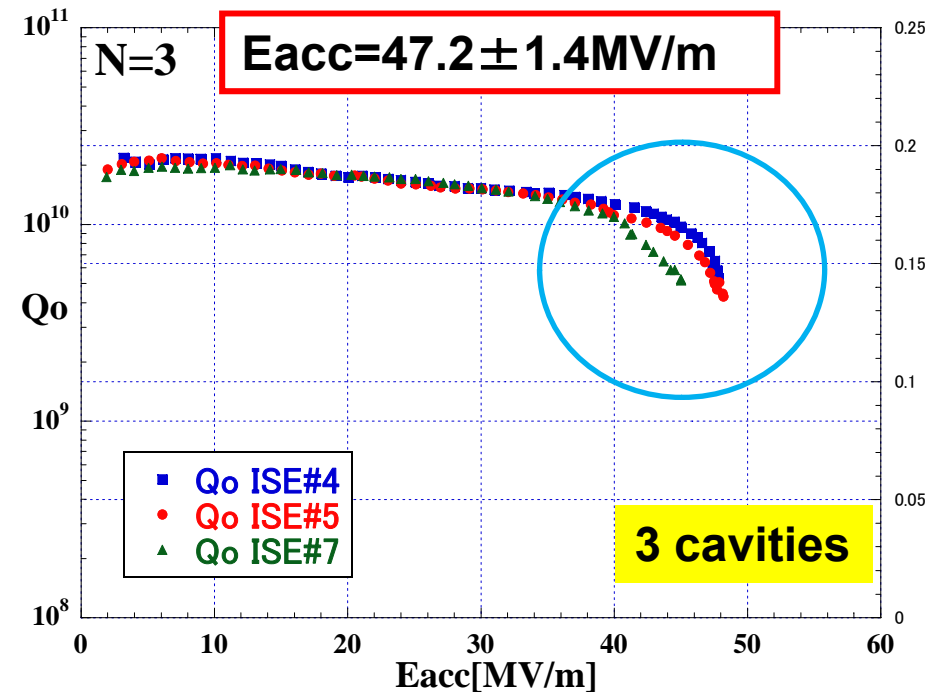
***FG + ICHIRO+ EP***

# Single cell cavities, FG+EP

Center cell single



Full end group single



Current best recipe for ICHIRO

CBP+CP+AN+EP(80 $\mu$ m)+EP(20 $\mu$ m)+flash EP(3 $\mu$ m)  
+Ethanol rinsing+Wiping+HPR+Bake

Q-slope issue remains.  
R&D for post EP cleaning, DDC.



# 9-cell cavities, FG+EP

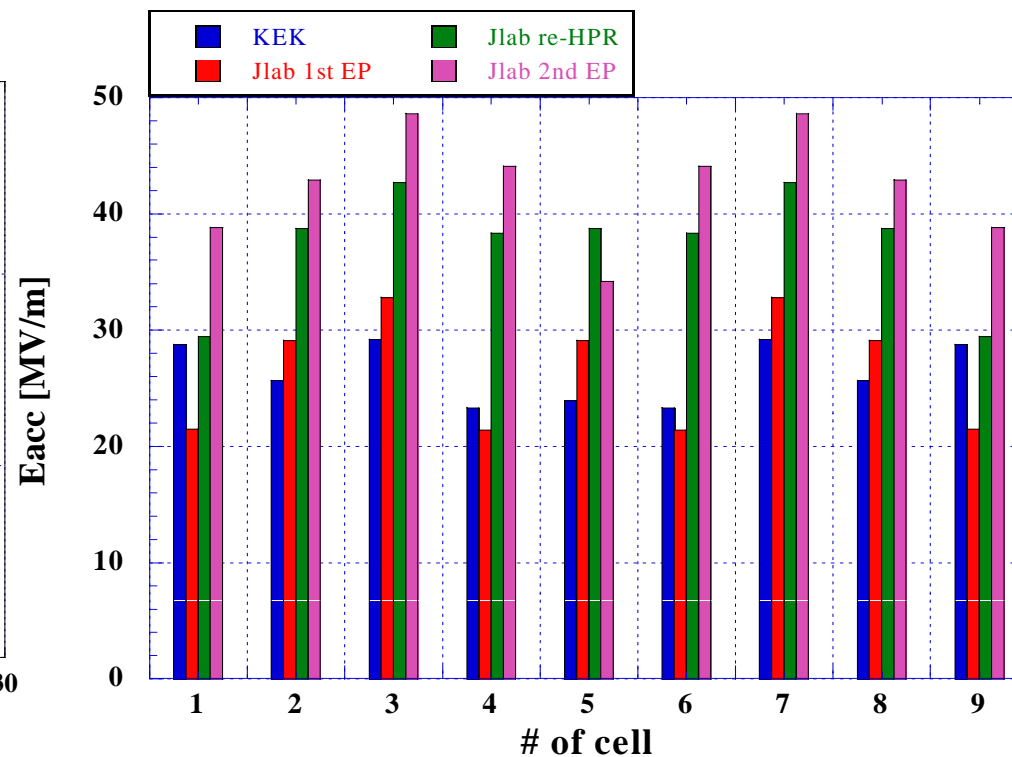
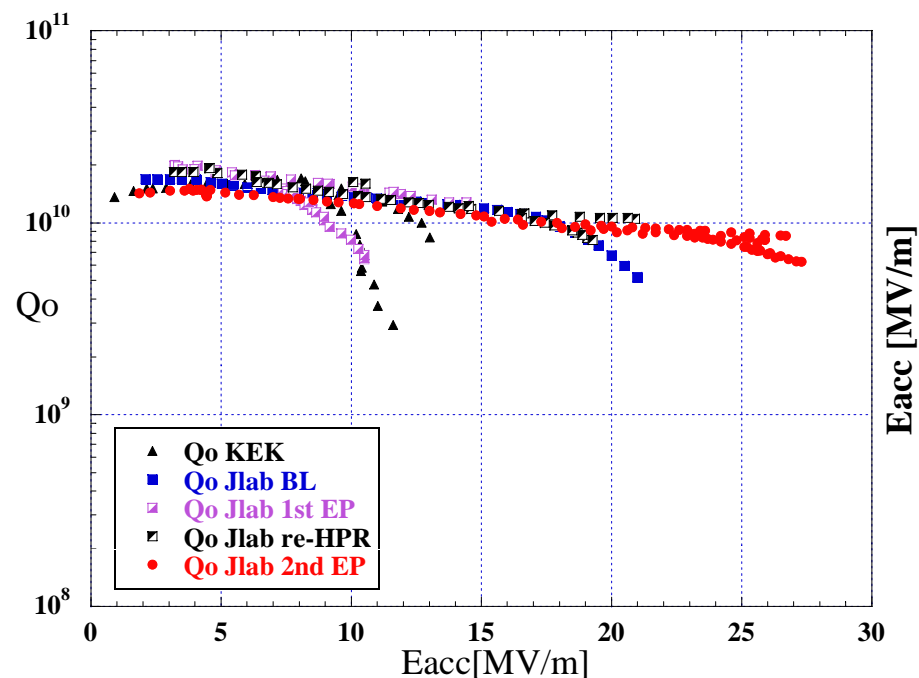
S0-study in 2010

Step-2 : full cavity

ICHIRO#7



Collaboration with Jlab/KEK in 2010, June~July, November~December.



***LG + ICHIRO + BCP***

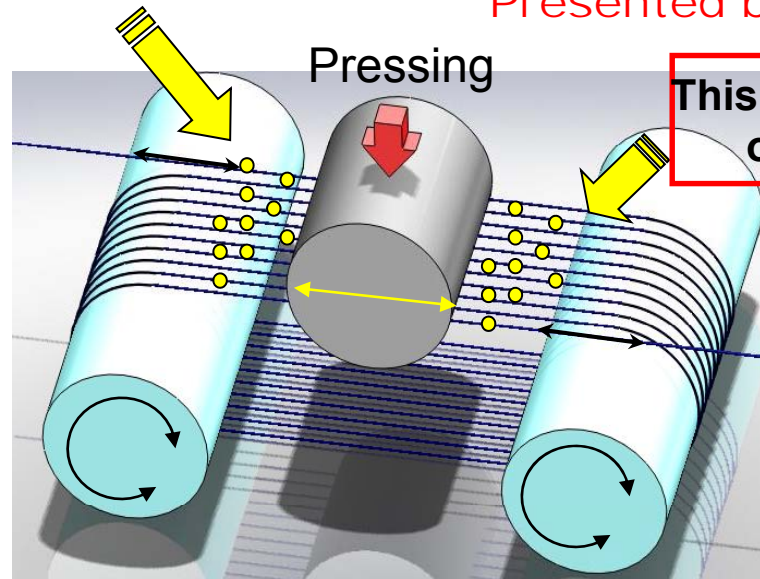
# Multi-Wire slicing @KEK/Tokyo Denkai

Conventional Silicon wafer  
slicing machine



Tokyo Denkai already  
installed this machine.

Presented by K. Saito at SRF2009



This is established technology  
on silicon wafer slicing.

Slicing used very thin  
piano wire ( $0.16\Phi$ )  
and liquid abrasive





# Experience of Multi-wire slicing

**2008July 6 sheets(2.8t)**  
**270Φ 20mmL**

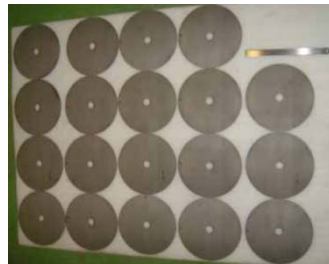


**ISE-LG**

**2008Sept. 58 sheets(3.2t for Jlab)**  
**270Φ 201mmL**



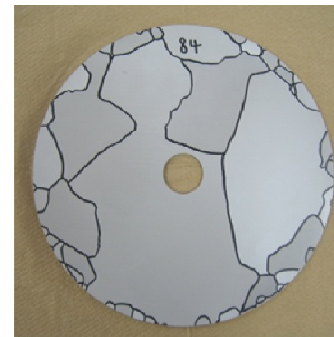
**2008Sept. 19 sheets (2.8t)**  
**270Φ 61mmL**



**LG-I9#9**



**2009Aug. 102 sheets(2.8t)**  
**265Φ 307mmL**



**LG-I9#10, 11**



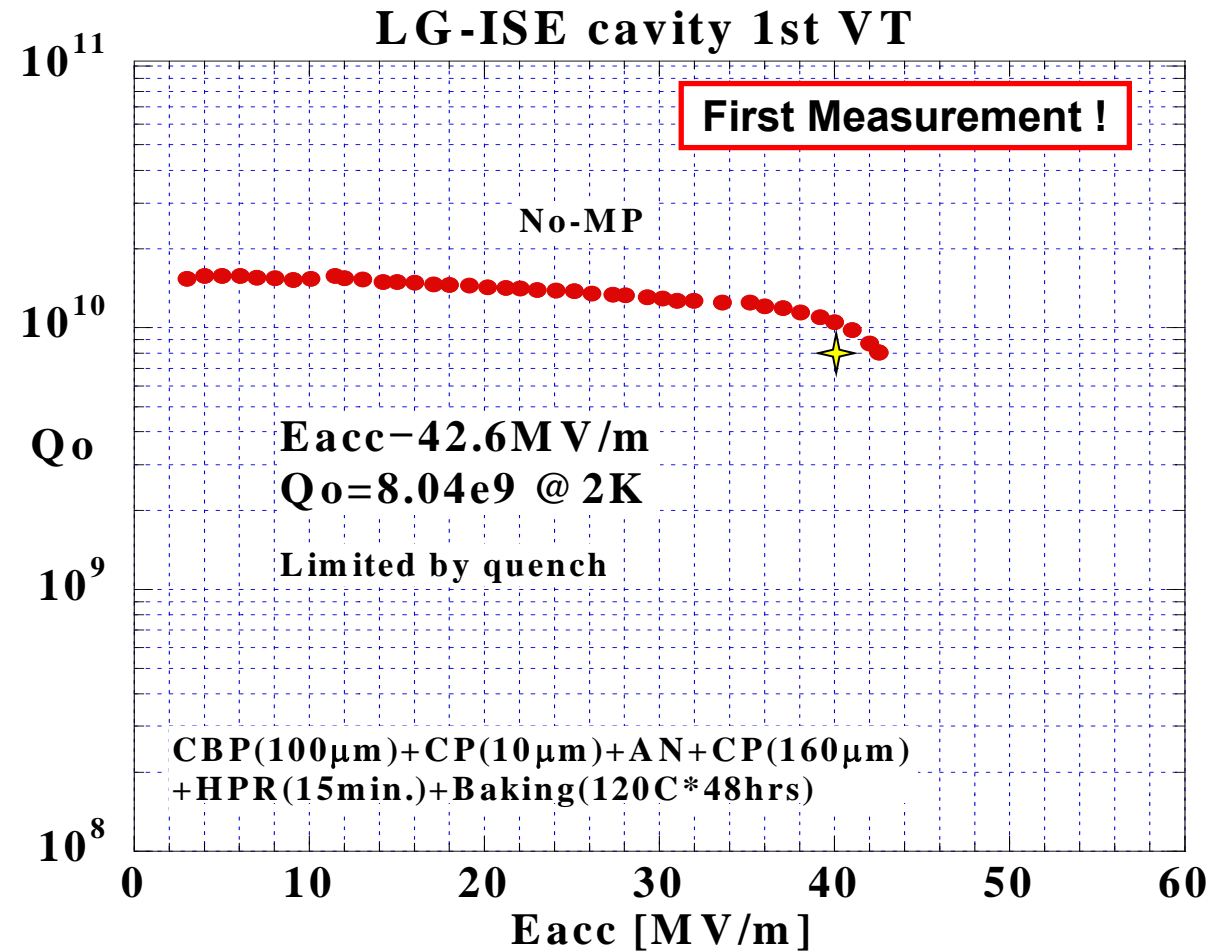


# Single cell, sliced LG Nb + BCP

bland new LG cavity + BCP



bland new  
LG-ISE

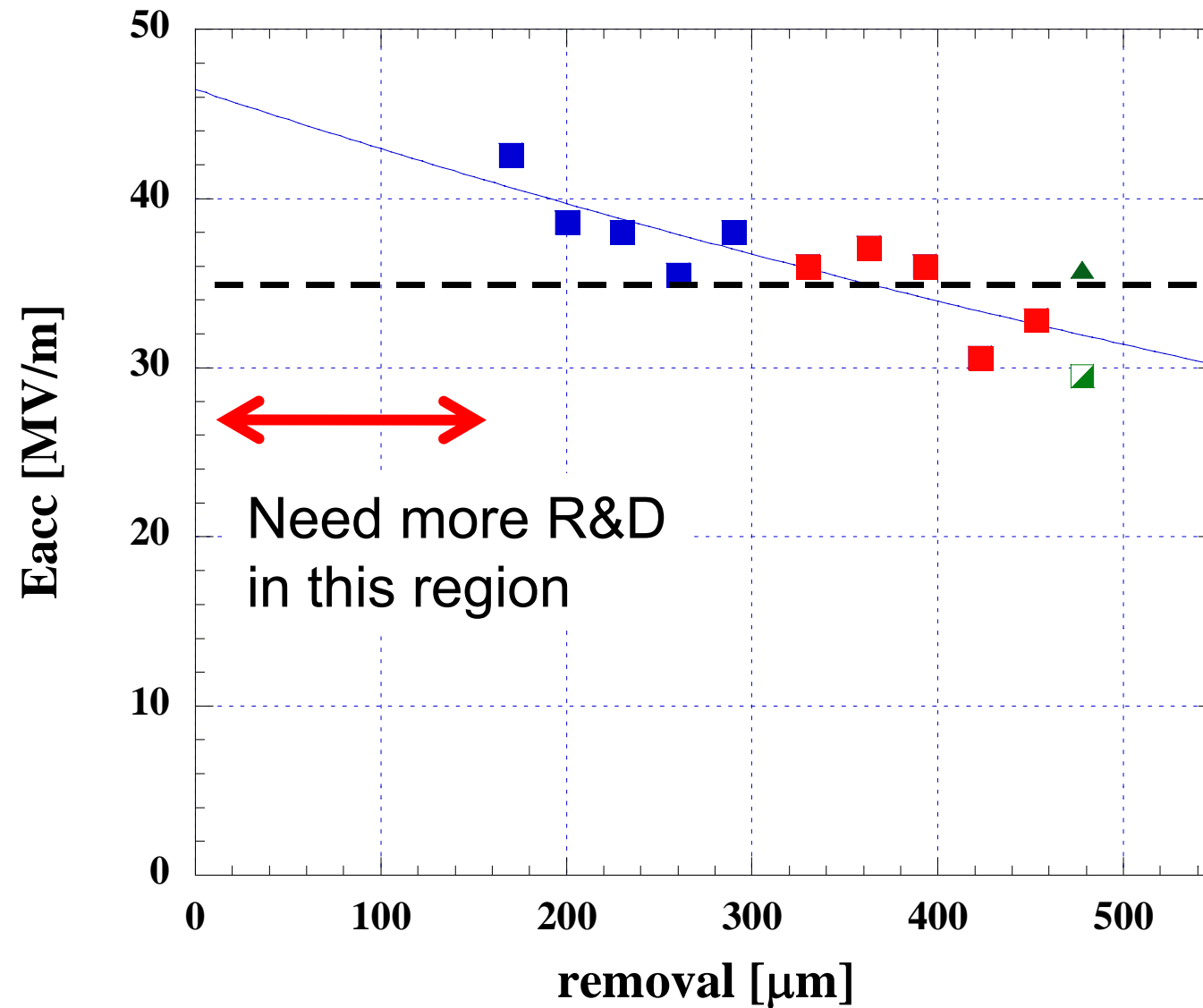


**Recipe**

CBP(80 $\mu\text{m}$ )+CP(10 $\mu\text{m}$ )+AN(750C\*3hrs)+CP(160 $\mu\text{m}$ )  
+HPR(15min.)+Baking(120C\*48hrs)

# LG single + BCP, Tight loop study

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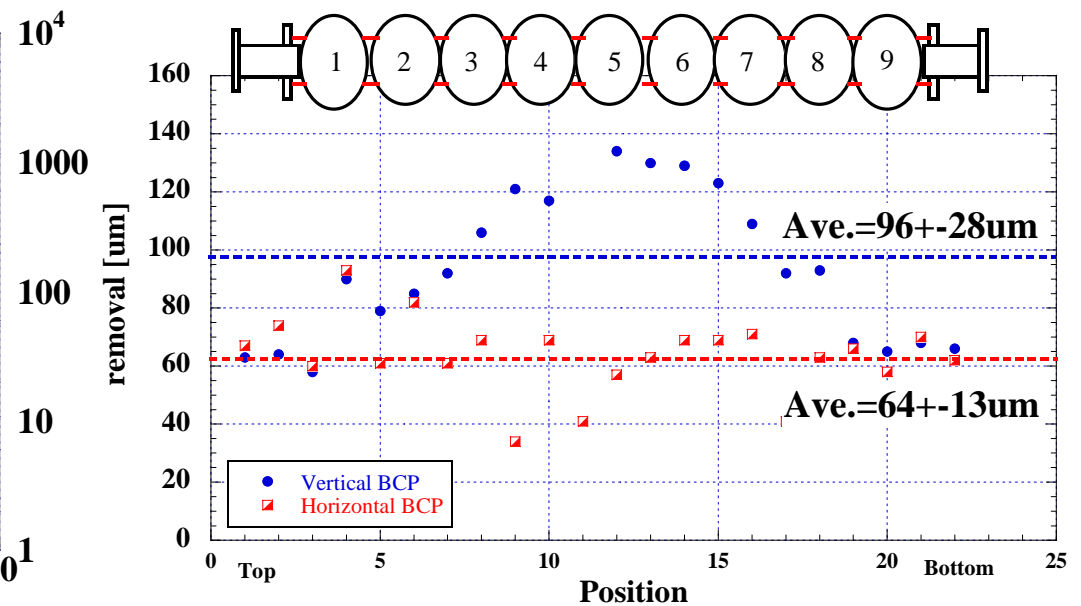
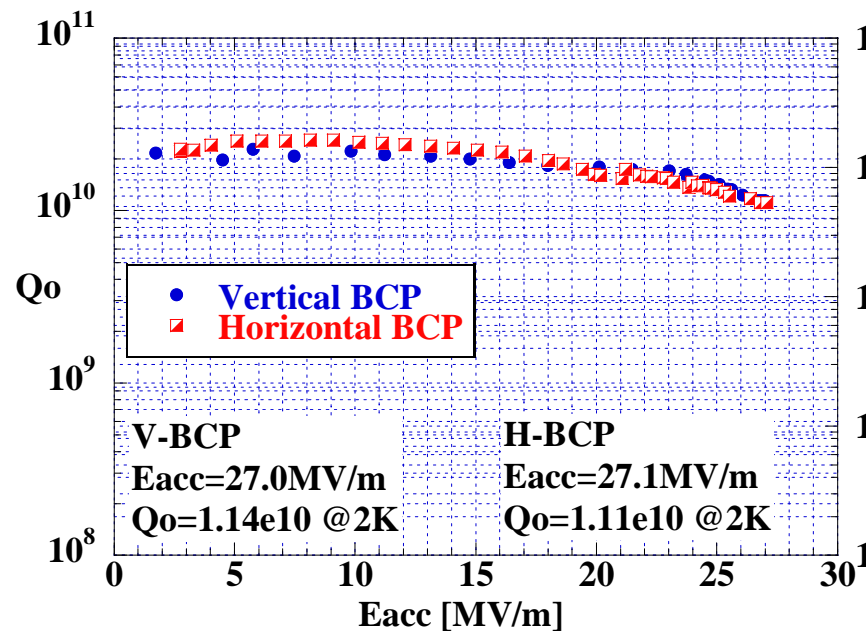


# LG ICHIRO 9-cell + BCP



**ICHIRO#9**

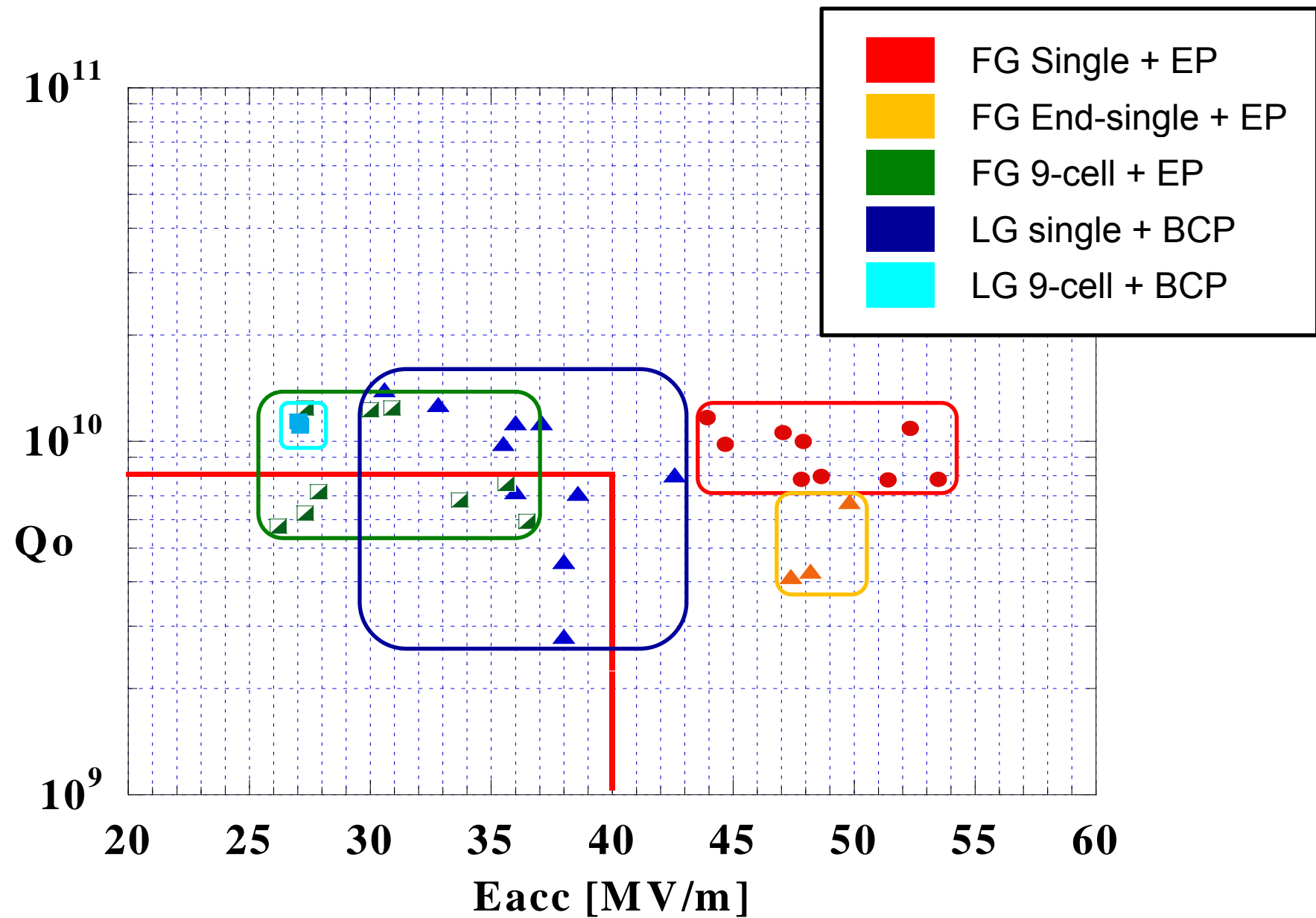
w/o end group



**Horizontal BCP produced uniform removal.**

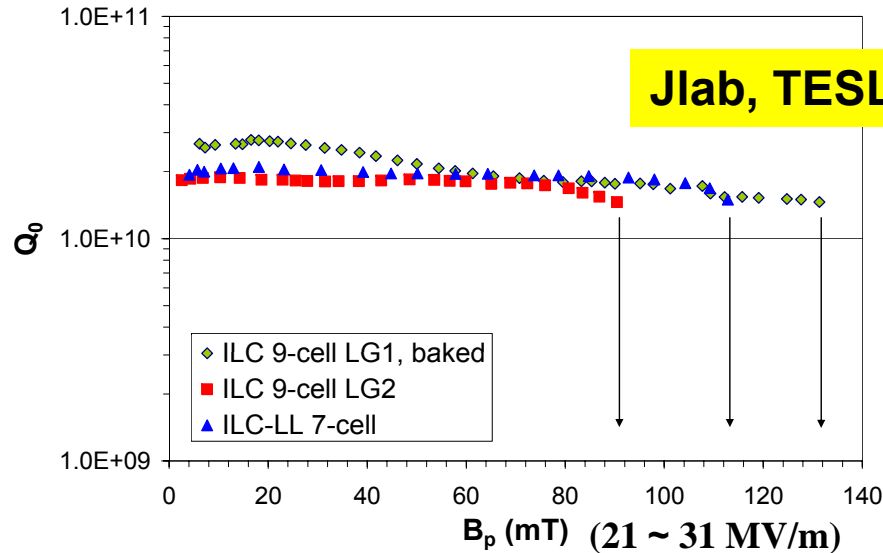
**Gradient was same as vertical BCP so far. We will continue H-BCP and VT.**

# Current status of ICHIRO cavities

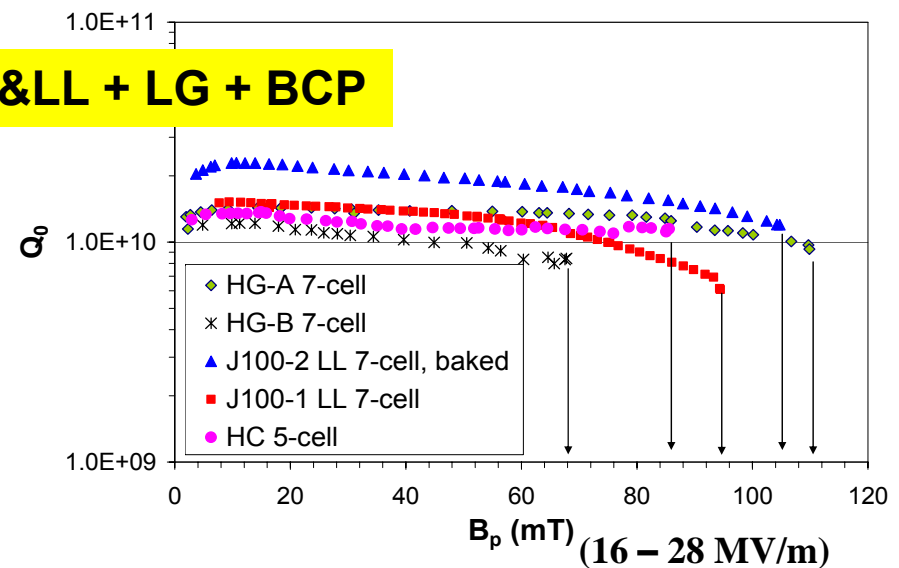


# Encouraged LG results from Jlab and DESY at SSTIN10

Test Results: **1300 MHz** cavities

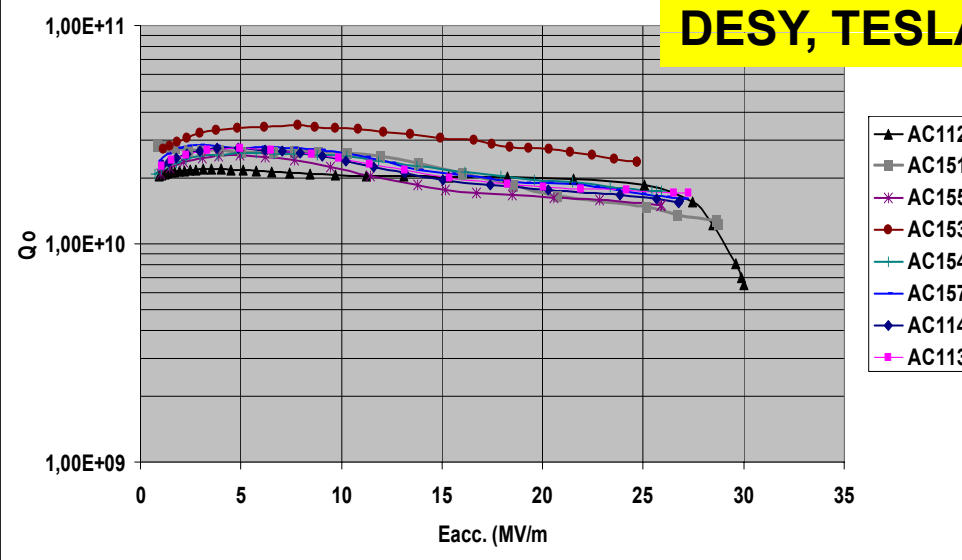


Test Results: **1497 MHz** cavities



Presented by Gianluigi Ciovati

DESY, TESLA+LG+BCP



DESY, LG 9-cell cavities  
(AC112 was not baked)

Presented by: B. Spaniol

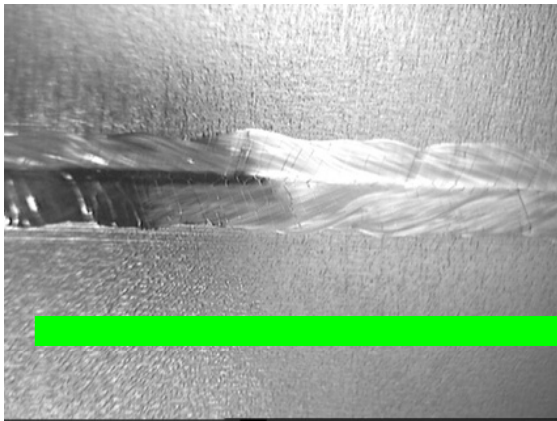
# ***Further R&D***

***1) Inner EBW***

***2) Single crystal ingot***

# Technical issue on EBW

As outer EBW typical



After 1<sup>st</sup> CBP



After final CBP



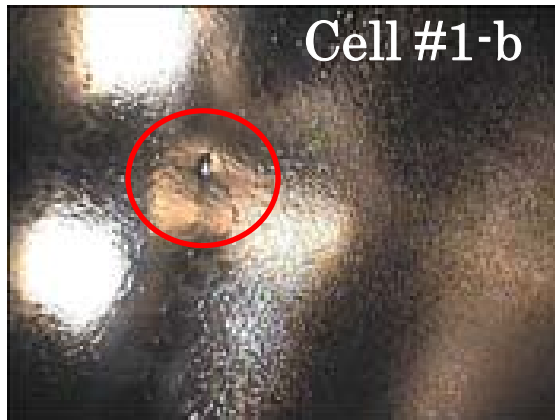
All EBW seam looks smooth and no defect after CBP.

After heavy EP (total~140 $\mu$ m), several defects were emerged at equator.

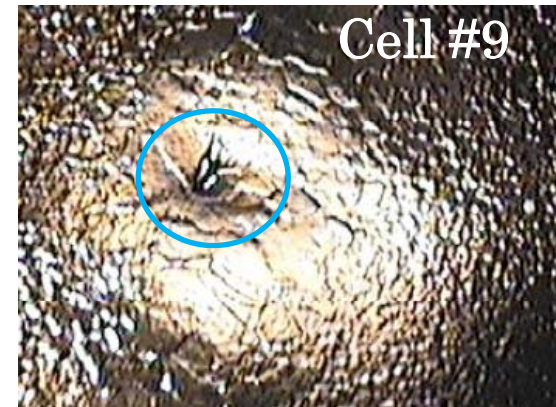
Cell #1-a



Cell #1-b



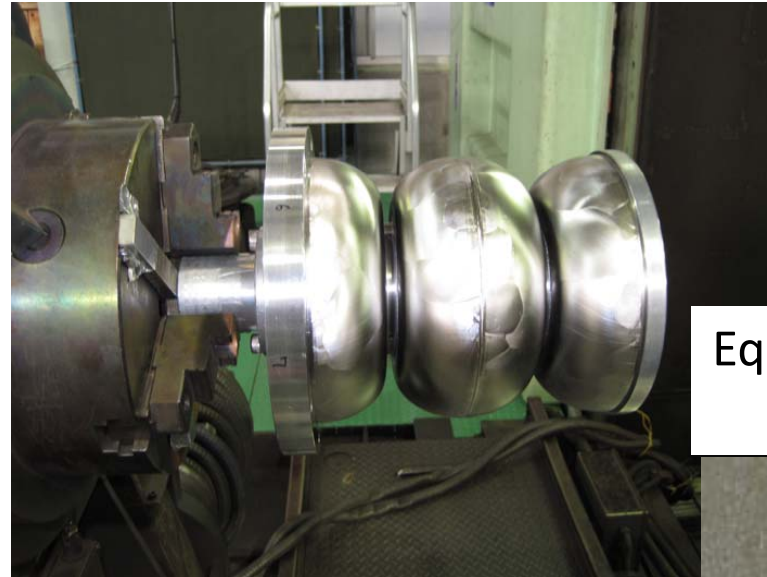
Cell #9



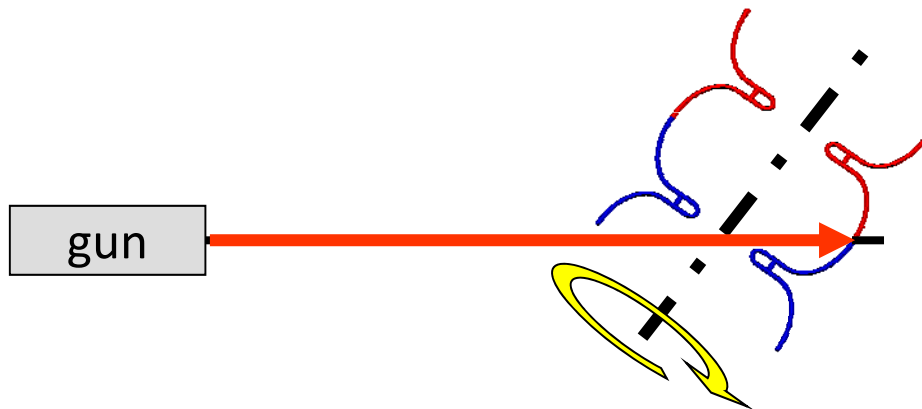
Our EBW is not yet qualified,  
sometimes very deep defect was there(~200 $\mu$ m).



# Inner EBW for all equator and iris



Equator seam  
(inside)



**All equator and iris parts can  
be welded by inner EBW.**



# EBW benefit on LG material

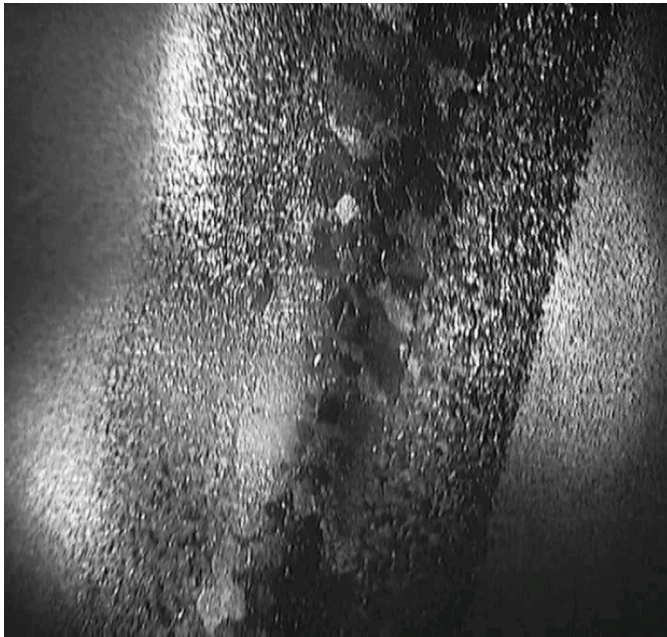
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## Fine grain

As EBW



After CBP  
+light BCP (10um)



Equator seam

## Large grain

As EBW



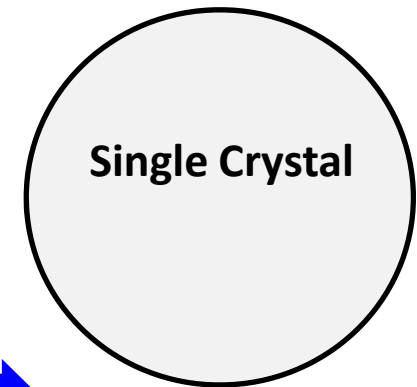
After CBP  
+light BCP (10um)



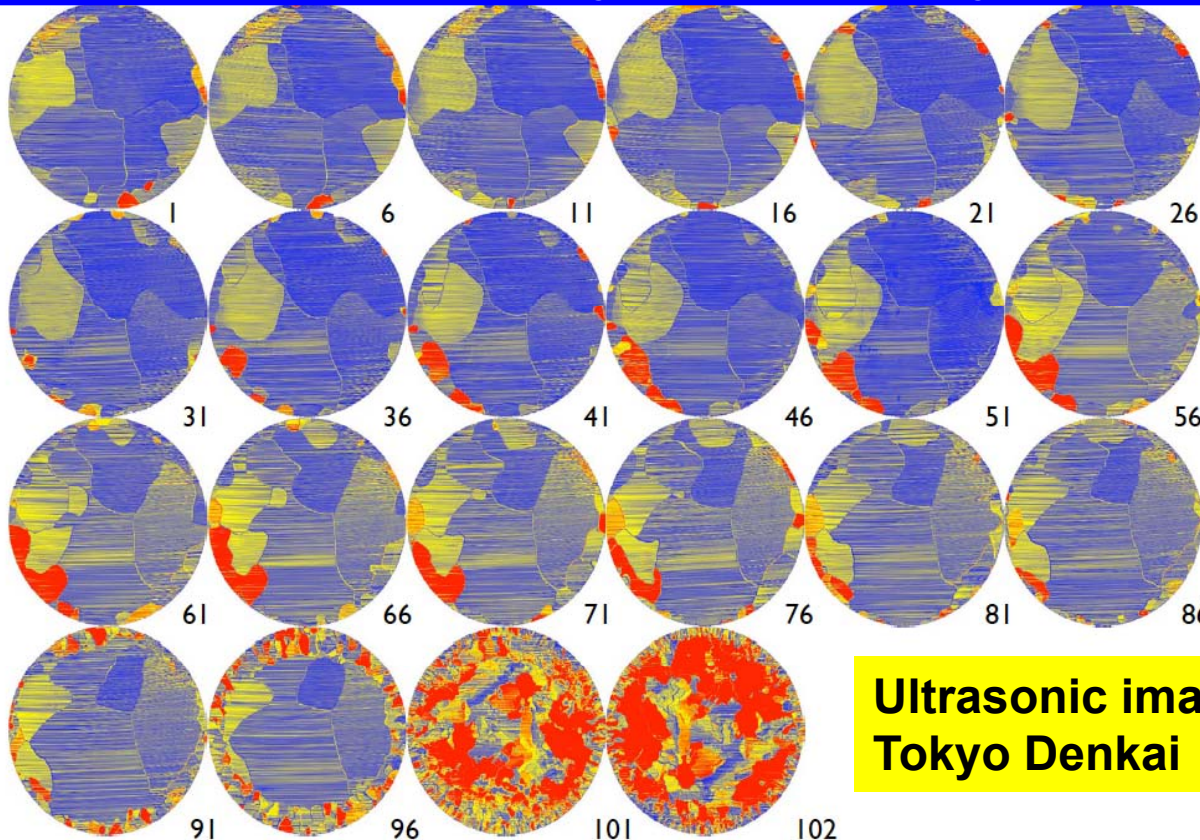
Equator seam



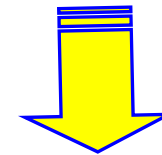
# Improvement of LG Ingot at Tokyo Denkai



Improvement of crystallization at Tokyo Denkai



Grain grow  
column like in  
EBM



Make a seed plate for  
single crystal ingot

Ultrasonic image by H.Umezawa  
Tokyo Denkai

# Summary

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## **Short term issue**

Proof of high gradient with FG+ICHIRO+EP

S0 study on ICHIRO#7(FG+EP) is on going in collaboration with Jlab/KEK.

Proof of high gradient with LG+ICHIRO+BCP.

Post EP cleaning for end-group will be essential for 50MV/m.

## **Long term issue**

Qualified cavity fabrication, EBW is main issue.

Reliable EBW technology by Inner EBW+LG.

R&D of single crystal ingot is on going in collaboration with KEK/Tokyo Denkai. The key is the seed material.

## **Final goal**

High gradient, high yield, low cost by the combination of LG/SC + LL/ICHIRO shape + BCP, inner EBW.